

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of

CHEN et al.

Atty. Ref.: 2476-36; Confirmation No. 2845

Appl. No. 10/730,382

TC/A.U. 1756

Filed: 9 December 2003

Examiner: Angebranndt Martin J.

For: REVERSIBLE PHOTBLEACHABLE MATERIALS BASED ON NANO-SIZED  
SEMICONDUCTOR PARTICLES AND THEIR OPTICAL APPLICATIONS

\* \* \* \* \*

February 28, 2007

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**RESPONSE TO RESTRICTION REQUIREMENT**

Responsive to the Official Action of August 29, 2006 (for which applicants hereby request any necessary time extension), please amend the above-identified patent application as follows: